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P/1250-293

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

New York, New York

Takushi YOSHIDA, et. al.

Date: November 14, 2005

Serial No.: 10/541,507

Group Art Unit:

Filed: July 8, 2005

Examiner:

For: SUBSTRATE PROCESSING SYSTEM, SUBSTRATE PROCESSING
APPARATUS, PROGRAM AND RECORDING MEDIUM

Commissioner for Patents
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Alexandria, VA 22313-1450

SUBMISSION

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Submitted herewith is a copy of art together with a form listing the same for the
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MAX MOSKOWITZ

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November 14, 2005
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Respectfully submitted,

MAX MOSKOWITZ

Registration No.: 30,576

OSTROLENK, FABER, GERB & SOFFEN, LLP
1180 Avenue of the Americas
New York, New York 10036-8403
Telephone: (212) 382-0700

APPLICANT'S ART CITATION (Use several sheets if necessary)		Application 10/541,507		OFGS File No. P1250-293	
		Applicant Takushi YOSHIDA, et. al.			
		Filing Date July 8, 2005		Group Art Unit	

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U.S. PATENT DOCUMENTS (not submitted for applications filed after 6/30/03)						
Examiner Initial	Document Number	Date MM-YYYY	Name	Class	Sub-class	Filing Date If Appropriate
	US-					
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FOREIGN PATENT DOCUMENTS							
	Document Number	Date MM-YYYY	Country	Class	Sub-class	Translation	
						Yes	No
	2004-025057	01-2004	Japan			Abstract	
	11-3117	01-1999	Japan			Abstract	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)		

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